

## DESCRIPTION

$\pi$ -CONJUGATED COMPOUND, CONDUCTIVE ORGANIC THIN  
FILM CONTAINING THE COMPOUND, AND FIELD-EFFECT  
5 TYPE ORGANIC TRANSISTOR EMPLOYING THE THIN FILM

## TECHNICAL FIELD

The present invention relates to a  $\pi$ -conjugated  
compound, a conductive organic thin film containing  
10 the  $\pi$ -conjugated compound, and a field effect type  
organic transistor, which are useful in electronic  
field such as display devices, information tags, and  
ICs.

## 15 BACKGROUND ART

The organic transistor employing an organic  
semiconductor can be formed on a plastic substrate  
and enables enlargement of a screen, which cannot  
readily be achieved by a silicon transistor. In  
20 particular, the organic transistor employing a  
soluble organic semiconductor can be produced at a  
lower cost without employing a vacuum process, and is  
promising for application to new devices such as  
flexible electronic paper sheets and information tags.

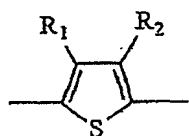
25 A  $\pi$ -conjugated compound and a device employing  
the  $\pi$ -conjugated compound are disclosed in Japanese  
Patent Application Laid-Open Nos. 2003-221434, 2003-

261655, 2003-268083, and 2003-292588.

#### DISCLOSURE OF THE INVENTION

The aforementioned soluble organic  
5 semiconductors typified by polymers have  
disadvantages: (1) a low mobility, (2) a low on-off  
ratio, (3) a high threshold, (4) less kinds of n-type  
semiconductors, (5) low stability, and so forth.  
Some improvement regarding the item (4) of the above  
10 disadvantage has been made, but is not sufficient.  
The present invention has been made to overcome the  
disadvantages of the prior art techniques. The  
present invention provides a  $\pi$ -conjugated compound, a  
conductive organic thin film containing the  $\pi$ -  
15 conjugated compound, and a field-effect type organic  
transistor and an electronic device employing this  
thin film to solve the above problems.

According to an aspect of the present invention,  
there is provided a  $\pi$ -conjugated compound which has  
20 two or more rings represented by Formula (I) and two  
or more rings represented by Formula (II), an odd  
number of rings being interposed between the rings of  
Formula (I), and an odd number of rings being  
interposed between the rings of Formula (II):



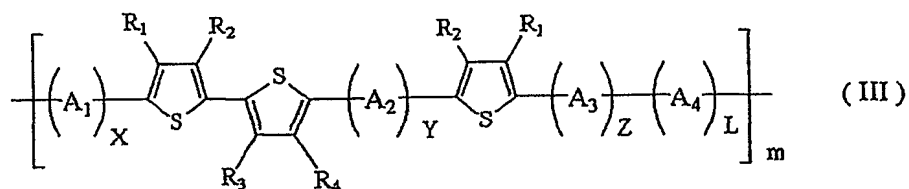
(I)



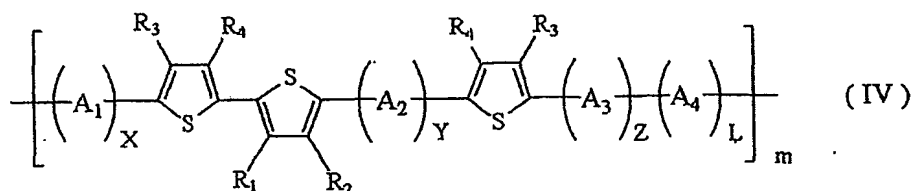
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where  $R_1$  and  $R_2$  are respectively hydrogen or a linear, cyclic, or branched alkyl group of 1 to 20 carbon atoms, at least one of  $R_1$  and  $R_2$  being not hydrogen, and  $CH_2$  of the alkyl group may be replaced by O, CO, S, or NH; and  $R_3$  and  $R_4$  are respectively hydrogen or a linear, cyclic, or branched perfluoroalkyl group of 1 to 20 carbon atoms, at least one of  $R_3$  and  $R_4$  being not hydrogen, and one or more of  $CF_2$  of the perfluoroalkyl group may be replaced by  $CH_2$ , O, CO, S, or NH.

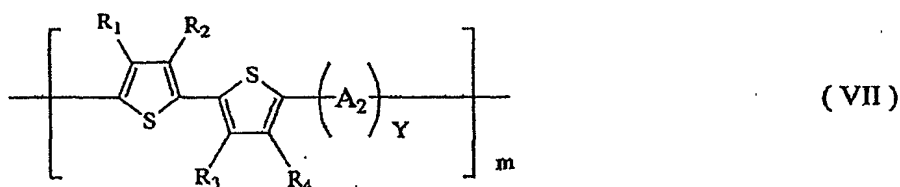
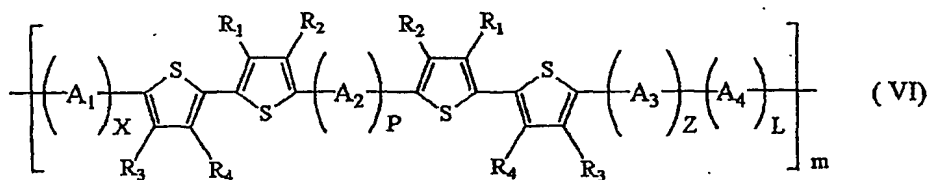
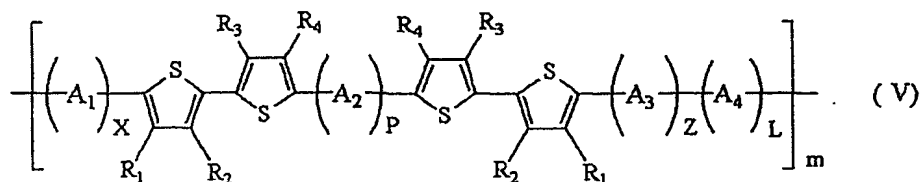
According to another aspect of the present invention, there is provided a  $\pi$ -conjugated compound represented by any of General Formulas (III) to (VII) below;



(III)



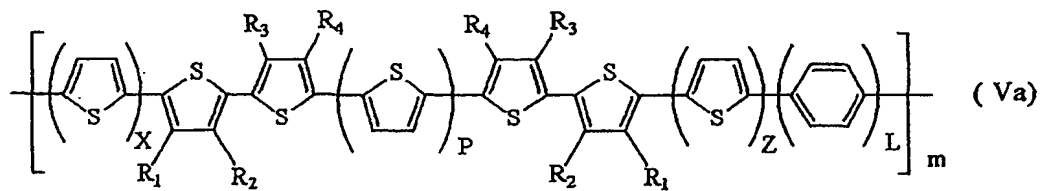
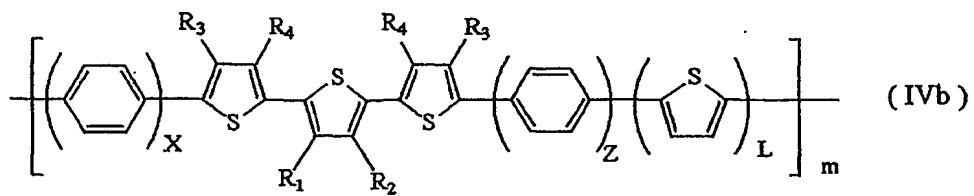
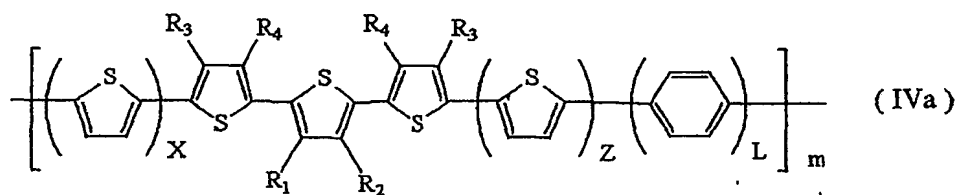
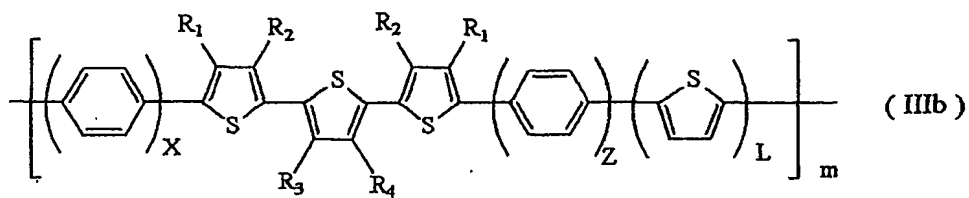
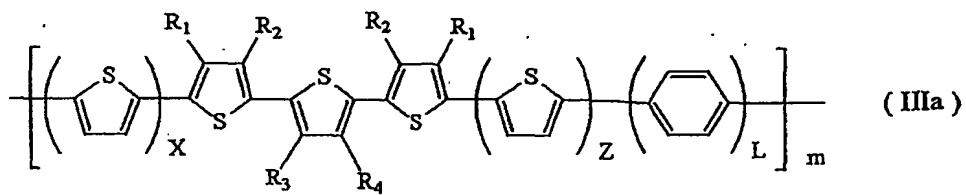
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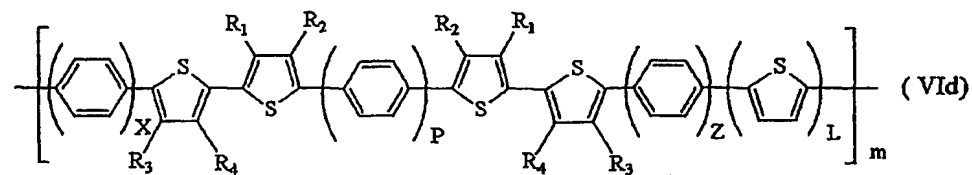
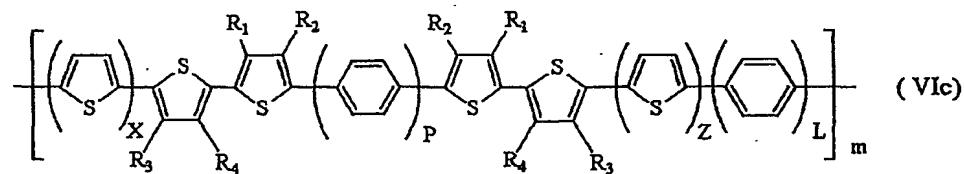
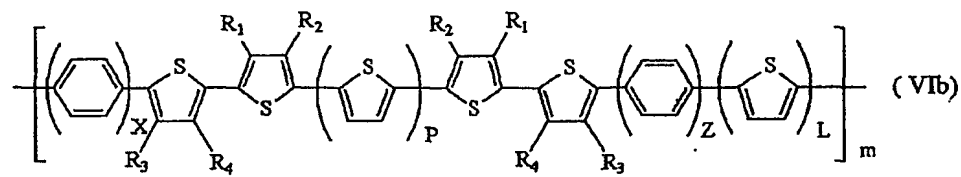
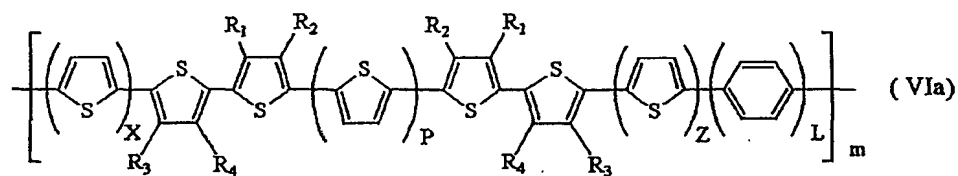
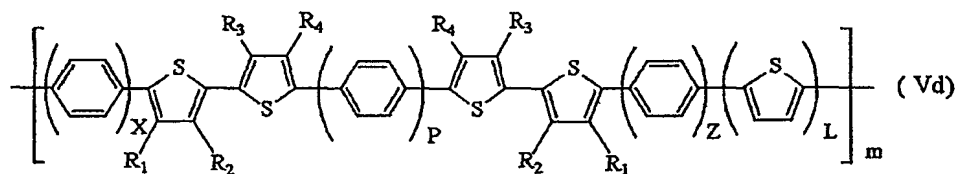
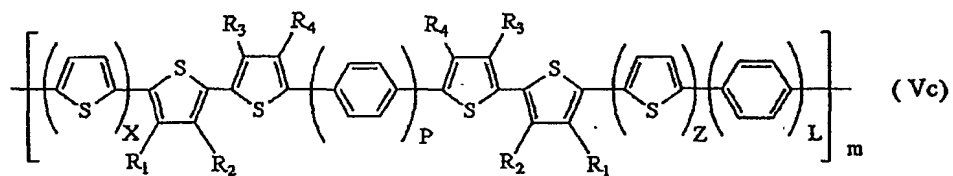
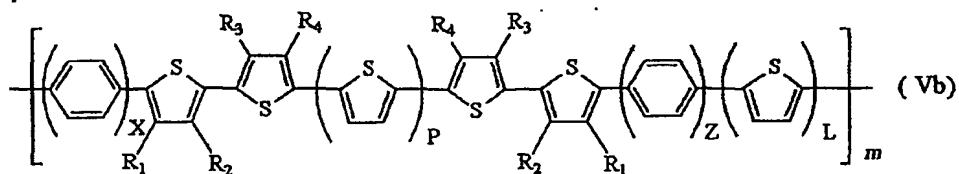


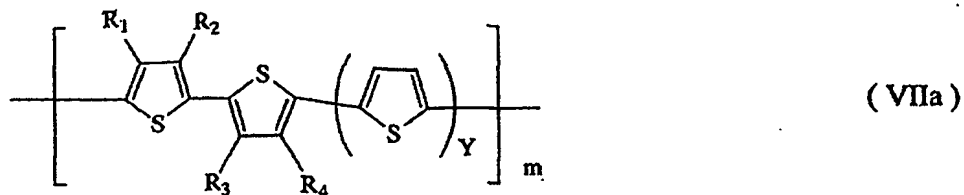
where R<sub>1</sub> and R<sub>2</sub> are respectively hydrogen or a linear,  
 5 cyclic, or branched alkyl group of 1 to 20 carbon  
 atoms, at least one of R<sub>1</sub> and R<sub>2</sub> being not hydrogen,  
 and one or more of CH<sub>2</sub> of the alkyl group may be  
 replaced by O, CO, S, or NH; R<sub>3</sub> and R<sub>4</sub> are  
 respectively hydrogen or a linear, cyclic, or  
 10 branched perfluoroalkyl group of 1 to 20 carbon atoms,  
 at least one of R<sub>3</sub> and R<sub>4</sub> being not hydrogen, and one  
 or more of CF<sub>2</sub> of the perfluoroalkyl group may be  
 replaced by CH<sub>2</sub>, O, CO, S, or NH; A<sub>1</sub>, A<sub>2</sub>, A<sub>3</sub>, and A<sub>4</sub>  
 represent respectively a linkage selected  
 15 independently from the group consisting of a single  
 bond, an alkylene group of 1 to 10 carbon atoms, a  
 -(CH=CH)<sub>r</sub>- group, and bivalent ring groups of

thiophene, furan, benzene, anthracene, and pentacene;  
one or more of CH groups in the ring may be replaced  
by N, or may have a substituent; r is an integer of 1  
to 10; X, Z, and L are respectively an integer of 0  
5 to 20 provided that the sum X+Z+L is an odd number; Y  
is an even number of not more than 20; P is an odd  
number not more than 19; and m is an integer of 2 or  
more.

According to still another aspect of the  
10 present invention, there is provided a  $\pi$ -conjugated  
compound represented by any of General Formulas  
(IIIa) to (VIIa) below;







where  $R_1$  and  $R_2$  are respectively hydrogen or a linear, cyclic, or branched alkyl group of 1 to 20 carbon atoms, at least one of  $R_1$  and  $R_2$  being not hydrogen, and one or more of  $\text{CH}_2$  of the alkyl group may be replaced by O, CO, S, or NH;  $R_3$  and  $R_4$  are respectively hydrogen or a linear, cyclic, or branched perfluoroalkyl group of 1 to 20 carbon atoms, at least one of  $R_1$  and  $R_2$  being not hydrogen, and one or more of  $\text{CF}_2$  of the perfluoroalkyl group may be replaced by  $\text{CH}_2$ , O, CO, S, or NH; X, Z, and L are respectively an integer of 0 to 20 provided that the sum  $X+Z+L$  is an odd number; Y is an even number of not more than 20; P is an odd number not more than 19; and m is an integer of 2 or more.

In the  $\pi$ -conjugated compounds of the present invention, X, Z, and L are respectively an integer of 0 to 6, Y is an even number of 6 or less, and P is an odd number of 5 or less, preferably.

Alternatively, in the  $\pi$ -conjugated compound of the present invention, m is preferably an integer of 2 to 500.

According to a further aspect of the present



invention, there is provided a conductive organic thin film containing the  $\pi$ -conjugated compound of the present invention.

According to a further aspect of the present invention, there is provided a conductive organic thin film, containing an organic compound, wherein the organic compound has, in the molecule, group or skeleton moieties capable of causing at least three kinds of intermolecular interactions, and the conductive organic thin film is constructed to have an ordered structure by alignment of the group or skeleton moieties between the molecules.

In the conductive organic thin film of the present invention, the intermolecular interactions preferably includes a  $\pi$ - $\pi$  interaction, an alkyl interaction, and a perfluoroalkyl interaction. Further, the organic compound is preferably aligned in the film in the conductive organic thin film.

According to a further aspect of the present invention, there is provided a field effect type organic transistor, constituted of three electrodes of a source electrode, a drain electrode, and a gate electrode, a gate insulating layer, and an organic semiconductor layer, wherein the organic semiconductor layer is a conductive organic thin film of the present invention.

In the field effect type organic transistor of

the present invention, molecules of the  $\pi$ -conjugated compound have respectively a long molecular axis aligned parallel to the direction of the source electrode and the drain electrode, preferably.

5           Alternatively, in the field effect type organic transistor of the present invention, molecules of the  $\pi$ -conjugated compound have respectively a long molecular axes aligned perpendicularly to the direction of the source electrode and the drain  
10 electrode, preferably.

The present invention provides a  $\pi$ -conjugated compound and a conductive organic thin film containing the compound which are useful in electronic application fields such as display device,  
15 information tags, and ICs. The present invention provides also a field effect type organic transistor which achieves a high mobility, a high on-off ratio, and high durability against external stimulation.

The present invention is explained below in  
20 more detail by reference to examples without limiting the invention in any way.

#### BRIEF DESCRIPTION OF THE DRAWINGS

Fig. 1 illustrates schematically of a lamella  
25 stack structure of the  $\pi$ -conjugated compound.

Fig. 2 illustrates schematically a defect portion of the lamella stack structure.

Fig. 3 illustrates schematically a conductive organic thin film of the present invention.

Fig. 4A shows a part of a  $\pi$ -conjugated compound of the present invention. Fig. 4B shows a part of a  
5  $\pi$ -conjugated compound which is not included in the compounds of the present invention.

Fig. 5 is a schematic sectional view of a field effect type organic transistor of the present invention.

10 Fig. 6 is a schematic sectional view of a field effect type organic transistor used in Examples.

Fig. 7 is a schematic sectional view of a field effect type organic transistor used in Examples.

## 15 BEST MODE FOR CARRYING OUT THE INVENTION

The process of investigation for designing the  $\pi$ -conjugated compound of the present invention is explained below. The conductive organic thin film of the present invention has an ordered structure  
20 constructed by at least three kinds of intermolecular interactions. Conductive organic thin films are explained in detail by reference to Figs. 1, 2, and 3. Fig. 1 illustrates schematically a lamella stack structure of a  $\pi$ -conjugated compound. A conductive  
25 organic thin film formed typically from poly(3-hexylpolythiophene) is known to have the lamella stack structure shown in Fig. 1. This stack

structure is suggested to contribute charge transport by a literature: Nature, 401, 685, 1999. This lamella stack structure is constructed by two kinds of intermolecular interactions: a  $\pi$ - $\pi$  interaction  
5 between thiophene rings, and an alkyl interaction between alkyl side chains, which are denoted by " $\pi$ " and "R" respectively in Figs. 1 to 3. Fig. 2 illustrates schematically a defect portion of the lamella stack structure. As shown in Fig. 2, owing  
10 to no more than two kinds of interactions, the alkyl interaction can coexist between the lamella layers, which tends to cause the defect 22. Fig. 3 illustrates schematically a conductive organic thin film of the present invention. As shown in Fig. 3,  
15 the interactions between the molecules are made stronger by utilizing three kinds of interactions, and thereby the distance between the interactions are increased in the lamella layer direction, making less liable the formation of defects between lamella  
20 layers. Therefore, the conductive organic thin film of the present invention has a structure for high charge transportability. The intermolecular interactions preferably include a  $\pi$ - $\pi$  interaction, an alkyl interaction, and a perfluoroalkyl interaction,  
25 which is denoted by "F" in Fig. 3. The  $\pi$ -conjugated compound of the present invention is molecular-designed based on the above idea. The structure of

the  $\pi$ -conjugated compound is made to have a skeleton exerting effectively the  $\pi$ - $\pi$  interaction, the alkyl interaction and the perfluoroalkyl interaction.

Hitherto,  $\pi$ -conjugated compounds are known  
5 which have an alkyl side chain or a perfluoroalkyl side chain. However, the known  $\pi$ -conjugated compounds have a random structure, being not controlled in structure for the effective alkyl interaction and perfluoroalkyl interaction.

10 The control of the structure is explained by reference to Figs. 4A and 4B. Fig. 4A illustrates schematically a part of a  $\pi$ -conjugated compound of the present invention. The numeral 41 denotes an alkyl side chain. The numeral 42 denotes a  
15 perfluoroalkyl side chain. The numerals 43 to 47 denote respectively a thiophene ring. The adjacent thiophene rings are reversed alternately by  $180^\circ$  owing to the interaction between the S atoms of the adjacent rings. Therefore, for example, the alkyl  
20 side chains of the thiophene rings 43 and 44 take the same side only when the odd number of thiophene rings exist between the thiophene ring 43 and the thiophene ring 44. Similarly, the perfluoroalkyl side chains of the thiophene rings 45, 46, and 47 take the same  
25 side only when the odd number of thiophene rings exist between the thiophene rings having the perfluoroalkyl side chain. With an even number of

the rings between the rings having the same kind of the side chains as shown in Fig. 4B, the side chains take opposite side, not giving the intended interaction. The  $\pi$ -conjugated compound of the  
5 present invention is accomplished on the basis of the above consideration.

The  $\pi$ -conjugated compound of the present invention has ring groups shown by the structural formulas (I) and (II), respectively two or more, in  
10 which an odd number of the rings exist between the two rings represented by the structural formula (I), and an odd number of the rings exist between the two rings represented by the structural formula (II).

The present invention provides the  $\pi$ -conjugated  
15 compound represented by any of the aforementioned General Formulas (III) to (VII).

Further the present invention provides the  $\pi$ -conjugated compound represented by any of General Formulas (IIIa) to (VIIa).

20 The rings having no side chain are limited in view of the solubility. Therefore, the symbols X, Z, and L are respectively an integer ranging from 0 to 6; Y being preferably an even number not more than 6 and P being preferably an even number of not more  
25 than 5; and m is preferably an integer ranging from 2 to 500.

Specific examples of the compounds are shown in

Tables 1 to 5, but the compounds are not limited thereto. The symbols used in the Tables denote the groups as shown below.

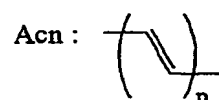
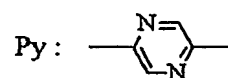
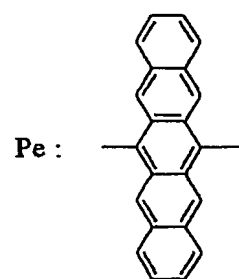
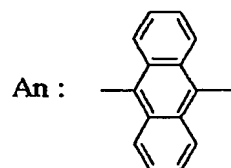
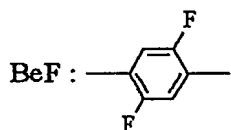
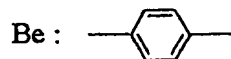
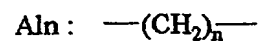
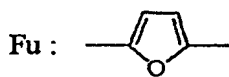
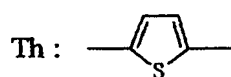
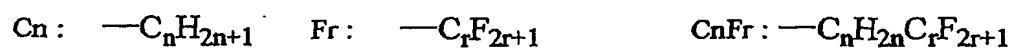


Table 1

No.	General Formula	R1	R2	R3	R4	A1	A2	A3	A4	X	Y	Z	L
III-1	III	C2	H	F3	F3	Th	-	Th	Th	1	0	1	1
III-2	III	C3	H	F6	F6	Th	-	Th	Th	1	0	1	1
III-3	III	C4	H	F10	F10	Th	-	Th	Th	1	0	1	1
III-4	III	C5	H	F6	F6	Th	-	Th	Th	1	0	1	1
III-5	III	C6	H	F6	F6	Th	-	Th	Th	1	0	1	1
III-6	III	C7	H	F6	F6	-	-	-	Th	0	0	0	1
III-7	III	C8	H	F6	F6	Th	-	Th	Th	2	0	2	1
III-8	III	H	C6	F6	F6	Th	-	Th	Th	1	0	1	1
III-9	III	H	C7	C6F3	C6F3	Th	-	Th	Th	1	0	1	1
III-10	III	H	C8	F9	H	Th	-	Th	Be	1	0	1	1
III-11	III	H	C9	F12	F12	Th	-	Th	Be	1	0	1	1
III-12	III	H	C10	F12	F12	Th	-	Th	Be	1	0	1	5
III-13	III	C6	C6	F6	F6	-	-	-	Be	0	0	0	3
III-14	III	C7	C7	F7	F7	Th	-	Th	Be	2	0	2	1
III-15	III	C8	C8	F8	F8	Th	-	Th	Be	1	0	1	1
III-16	III	C2	H	C6F4	C6F4	Be	-	Be	Th	1	0	1	3
III-17	III	C3	H	F6	F6	Be	-	Be	Th	1	0	1	1
III-18	III	C4	H	F10	F10	Be	-	Be	Th	1	0	1	1
III-19	III	C5	H	F6	F6	Be	-	Be	Th	1	0	1	1
III-20	III	C6	H	F6	H	Be	-	Be	Th	1	0	1	1
III-21	III	C7	H	F6	F6	Be	-	Be	Th	3	0	3	1
III-22	III	C8	H	F6	F6	Be	-	Be	Th	1	0	1	1
III-23	III	H	C6	C6F4	C6F4	Be	-	Be	Th	1	0	1	1
III-24	III	H	C7	F8	F8	Be	-	Be	Th	1	0	1	1
III-25	III	H	C8	F9	F9	Be	-	Be	Be	1	0	1	1
III-26	III	H	C9	F12	F12	Be	-	Be	Be	1	0	1	1
III-27	III	H	C10	F12	F12	Be	-	Be	Be	1	0	1	3
III-28	III	C6	C6	F6	F6	Be	-	Be	Be	1	0	1	1
III-29	III	C7	C7	F7	H	Be	-	Be	Be	4	0	4	1
III-30	III	C8	C8	F8	F8	Be	-	Be	Be	1	0	1	1
III-31	III	C6	C6	F6	F6	Th	Th	Th	Th	1	2	1	1
III-32	III	C6	C6	F6	F6	Th	-	Th	Fu	1	0	1	1
III-33	III	C6	C6	F6	F6	Th	-	Th	BeF	1	0	1	1
III-34	III	C6	C6	F6	F6	Th	-	Th	An	1	0	1	1
III-35	III	C6	C6	C6F4	C6F4	Th	-	Th	Th	1	0	1	1
III-36	III	H	C6	F6	F6	Th	-	Th	Th	1	0	1	18
III-37	III	OC6	H	F6	H	Th	-	Th	Th	1	0	1	3
III-38	III	H	C6	H	OC2F6	Th	-	Th	Th	1	0	1	1



Table 2

No.	General Formula	R1	R2	R3	R4	A1	A2	A3	A4	X	Y	Z	L
IV-1	IV	C2	C2	F3	H	Th	-	Th	Th	1	0	1	1
IV-2	IV	C3	C3	F6	H	Th	-	Th	Th	1	0	1	1
IV-3	IV	C4	C4	F10	H	-	-	-	Th	0	0	0	3
IV-4	IV	C5	C5	F6	H	Th	-	Th	Th	1	0	1	1
IV-5	IV	C6	C6	H	F3	Th	-	Th	Th	1	0	1	1
IV-6	IV	C6	C6	F5	H	Th	-	Th	Th	1	0	1	1
IV-7	IV	C6	C6	F6	H	Th	-	Th	Th	1	0	1	1
IV-8	IV	C6	C6	F8	H	Th	-	Th	Th	1	0	1	1
IV-9	IV	C7	C7	H	F8	Th	-	Th	Be	2	0	2	1
IV-10	IV	C4	C4	F4	H	Th	-	Th	Be	1	0	1	1
IV-11	IV	C8	C8	F12	H	Th	-	Th	Be	1	0	1	3
IV-12	IV	C6	C6	F8	H	-	-	-	Be	0	0	0	1
IV-13	IV	C9	C9	H	F6	Th	-	Th	Be	10	0	10	1
IV-14	IV	C10	C10	H	C3F10	Th	-	Th	Be	1	0	1	1
IV-15	IV	C14	C14	H	F8	Th	-	Th	Be	1	0	1	1
IV-16	IV	C2	H	F3	H	Be	-	Be	Th	1	0	1	1
IV-17	IV	C3	C3	F6	H	Be	-	Be	Th	1	0	1	1
IV-18	IV	C4	C4	F10	H	Be	-	Be	Th	6	0	6	1
IV-19	IV	C5	C5	F6	H	Be	-	Be	Th	1	0	1	1
IV-20	IV	C6	C6	H	F3	Be	-	Be	Th	1	0	1	7
IV-21	IV	C6	C6	F5	H	Be	-	Be	Th	1	0	1	1
IV-22	IV	C6	C6	C6F8	H	-	-	-	Th	0	0	0	5
IV-23	IV	C6	C6	F8	H	Be	-	Be	Th	1	0	1	1
IV-24	IV	C7	C7	H	F8	Be	-	Be	Be	1	0	1	1
IV-25	IV	C8	C8	H	F9	Be	-	Be	Be	1	0	1	1
IV-26	IV	H	C8	F12	H	Be	-	Be	Be	1	0	1	9
IV-27	IV	C8	C8	H	F12	Be	-	Be	Be	4	0	4	1
IV-28	IV	C9	C9	H	F6	Be	-	Be	Be	1	0	1	1
IV-29	IV	C10	C10	H	F7	Be	Be	Be	Be	1	2	1	1
IV-30	IV	C14	C14	H	F8	Be	-	Be	Be	1	0	1	1
IV-31	IV	C6	C6	F6	F6	Be	-	Be	Pe	1	0	1	1
IV-32	IV	C6	C6	F6	F6	Be	-	Be	Py	1	0	1	1
IV-33	IV	C6	C6	F6	F6	Th	-	Th	Th	1	0	1	1
IV-34	IV	H	C6	C3F6	C3F6	Th	-	Th	Th	1	0	1	1
IV-35	IV	C6	C6	C4F8	C4F8	Th	-	Th	Be	1	0	1	1
IV-36	IV	C4	C4	F4	H	-	-	-	Th	0	0	0	1
IV-37	IV	OC6	OC6	F5	H	-	-	-	Th	0	0	0	1
IV-38	IV	C6	C6	F6	H	-	Th	-	Th	0	4	0	1

Table 3

No.	General Formula	R1	R2	R3	R4	A1	A2	A3	A4	X	P	Z	L
V-1	V	C1	H	F3	F3	Th	Th	Th	Th	1	1	1	1
V-2	V	C3	H	F6	F6	Th	Be	Th	Th	1	1	1	1
V-3	V	C4	H	F10	F10	Th	Th	Th	Th	2	1	2	1
V-4	V	C5	H	H	F6	Th	Be	Th	Th	1	1	1	1
V-5	V	C6	H	F6	F6	Th	Th	Th	Th	1	1	1	1
V-6	V	C8	H	C3F6	H	Th	Be	Th	Th	1	3	1	1
V-7	V	C20	H	F6	F6	Th	Th	Th	Th	1	1	1	1
V-8	V	H	C6	H	F6	Th	Be	Th	Th	1	1	1	1
V-9	V	H	C7	F8	F8	Th	Th	Th	Be	1	1	1	1
V-10	V	H	C8	H	F9	Th	Be	Th	Be	1	1	1	1
V-11	V	H	C9	F12	F12	Th	Th	Th	Be	1	1	1	1
V-12	V	H	C18	C5F12	H	Th	Be	Th	Be	1	5	1	1
V-13	V	C6	C6	F6	F6	Th	Th	Th	Be	1	1	1	1
V-14	V	C7	C7	C4F7	C4F7	Th	Be	Th	Be	1	1	1	1
V-15	V	C8	C8	F8	F8	Th	Th	Th	Be	1	3	1	1
V-16	V	C2	H	F3	F3	Be	Be	Be	Th	1	3	1	1
V-17	V	C3	H	F6	F6	Be	Th	Be	Th	3	1	3	1
V-18	V	C4	H	F10	F10	Be	Be	Be	Th	1	1	1	1
V-19	V	C5	H	F6	F6	Be	Th	Be	Th	1	1	1	11
V-20	V	C6	H	F6	F6	Be	Be	Be	Th	1	1	1	1
V-21	V	C7	H	F6	F6	Be	Th	Be	Th	1	15	1	1
V-22	V	C8	H	F6	F6	Be	Be	Be	Th	1	1	1	1
V-23	V	H	C6	F6	F6	Be	Th	Be	Th	4	1	4	1
V-24	V	H	C7	F8	F8	Be	Be	Be	Be	1	1	1	1
V-25	V	H	C8	F9	F9	Be	Th	Be	Be	1	3	1	19
V-26	V	H	C9	F12	F12	Be	Be	Be	Be	1	3	1	1
V-27	V	H	C10	F12	F12	Be	Th	Be	Be	1	1	1	1
V-28	V	C6	C6	F6	F6	Be	Be	Be	Be	1	1	1	1
V-29	V	C7	C7	F7	F7	Be	Th	Be	Be	1	1	1	1
V-30	V	C8	C8	F8	F8	Be	Be	Be	Be	1	1	1	1
V-31	V	C6	C6	H	F6	Be	Be	Be	Be	1	1	1	1
V-32	V	H	C6	F6	F6	-	Th	-	Be	0	1	0	1
V-33	V	C6	C6	F6	H	-	Th	-	Be	0	3	0	1
V-34	V	C6	H	F6	F6	-	Th	-	Be	0	5	0	1
V-35	V	C6	C6	H	F6	-	Th	-	Be	0	1	0	3

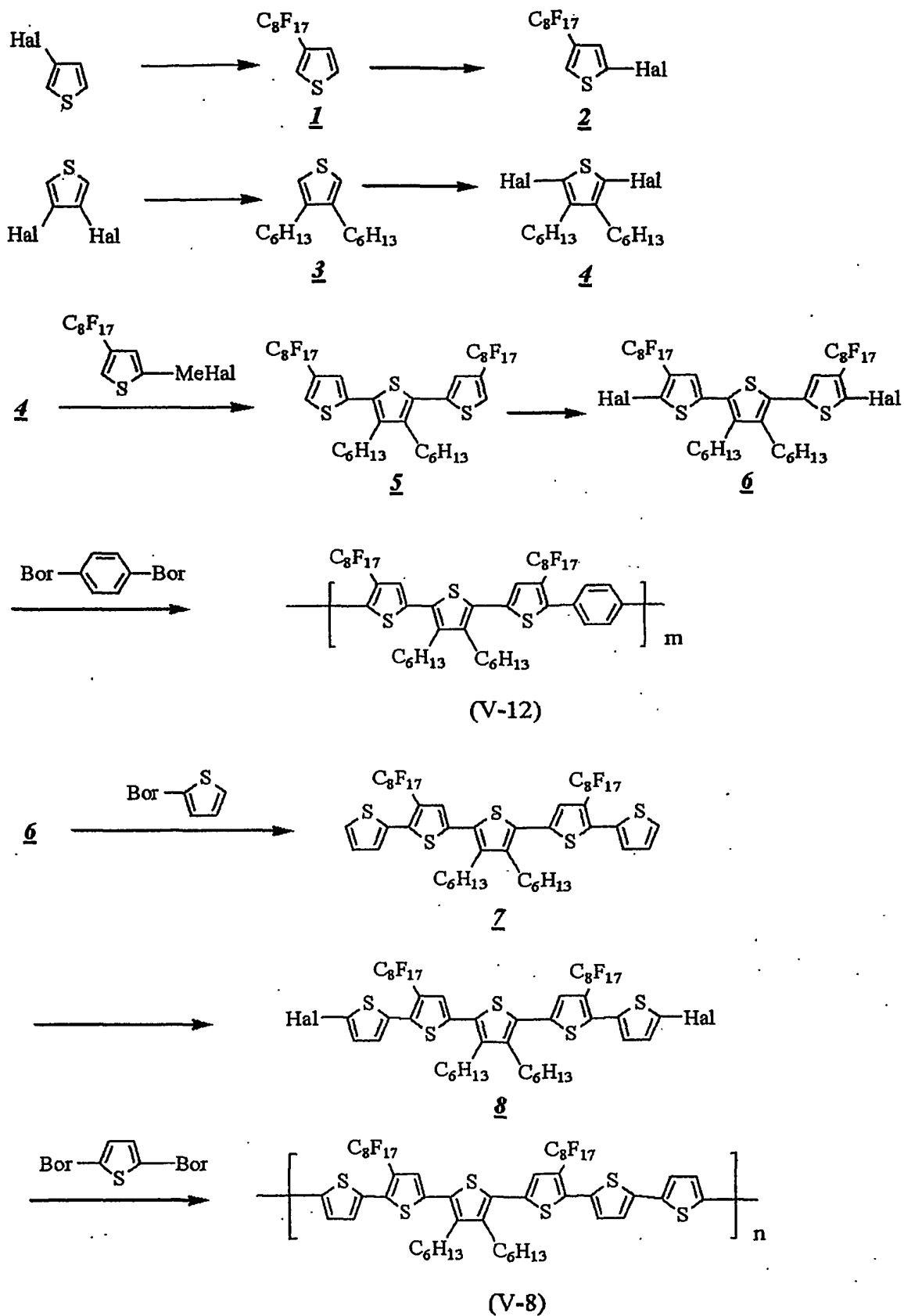
Table 4

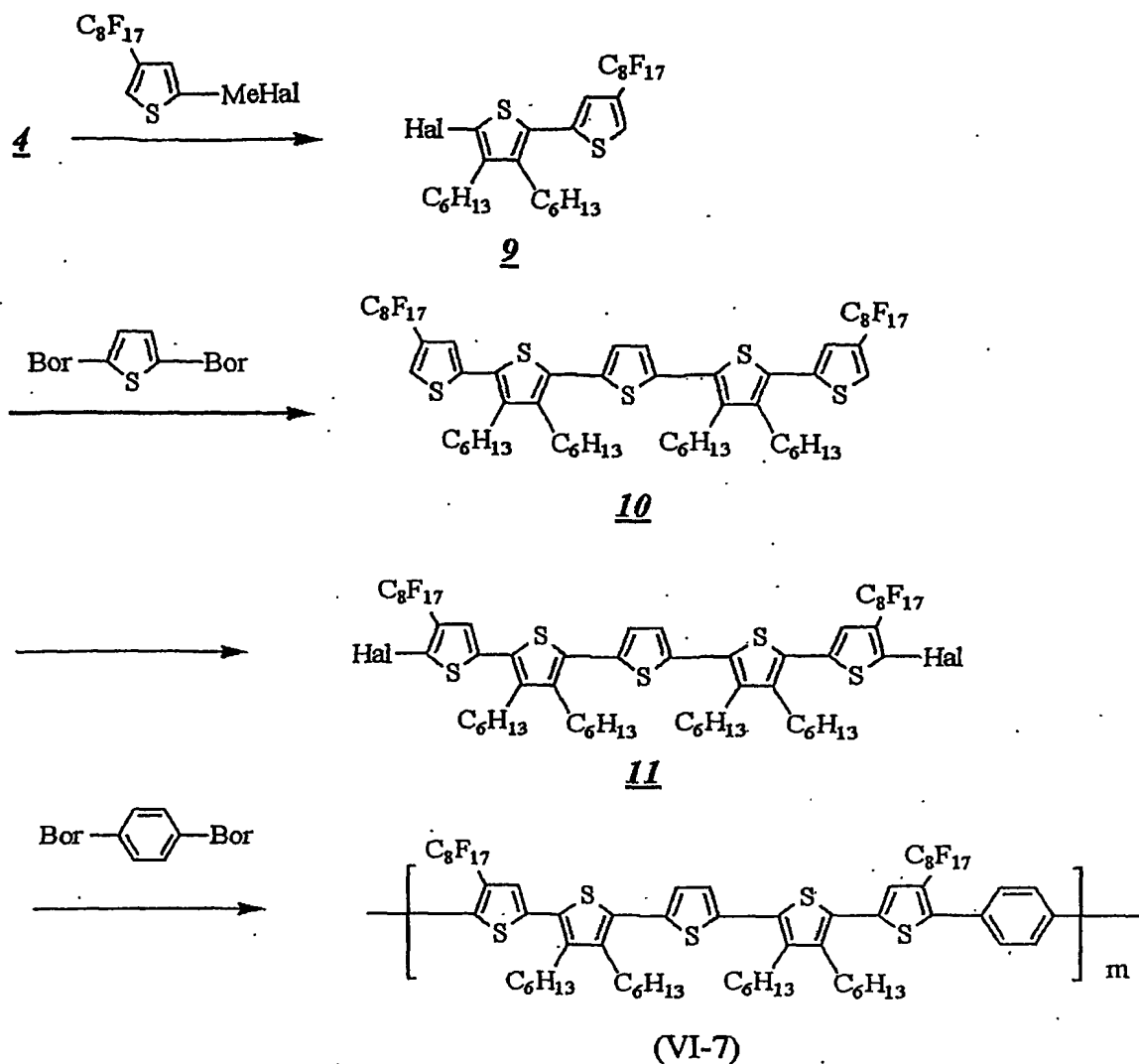
No.	General Formula	R1	R2	R3	R4	A1	A2	A3	A4	X	P	Z	L
VI-1	VI	C2	C2	F3	H	Th	Th	Th	Th	1	13	1	1
VI-2	VI	C3	C3	F6	H	Th	Be	Th	Th	1	1	1	1
VI-3	VI	H	C4	F10	H	Th	Th	Th	Th	1	1	1	1
VI-4	VI	C5	C5	F6	H	Th	Be	Th	Th	1	3	1	1
VI-5	VI	C6	C6	H	F3	Th	Th	Th	Th	1	1	1	1
VI-6	VI	C6	C6	F5	H	Th	Be	Th	Th	1	1	1	1
VI-7	VI	C6	C6	F8	H	-	Th	-	Be	0	1	0	1
VI-8	VI	H	C6	F8	H	Th	Be	Th	Th	1	1	1	1
VI-9	VI	C7	C7	H	F8	Th	Th	Th	Be	1	9	1	1
VI-10	VI	C8	C8	H	F9	Th	Be	Th	Be	12	1	12	1
VI-11	VI	C8	H	F12	H	Th	Th	Th	Be	1	1	1	1
VI-12	VI	C8	C8	H	C3F12	Th	Be	Th	Be	1	1	1	1
VI-13	VI	C9	C9	H	F6	Th	Th	Th	Be	1	1	1	1
VI-14	VI	C10	C10	F8	H	-	Th	-	Th	0	1	0	1
VI-15	VI	C14	H	H	F8	Th	Th	Th	Be	1	19	1	1
VI-16	VI	C2	C2	F3	H	Be	Be	Be	Th	1	1	1	1
VI-17	VI	C3	C3	F6	H	Be	Th	Be	Th	1	1	1	1
VI-18	VI	C4	C4	C2F10	H	Be	Be	Be	Th	1	3	1	1
VI-19	VI	H	C5	F6	H	Be	Th	Be	Th	1	3	1	1
VI-20	VI	C6	C6	H	F3	Be	Be	Be	Th	1	3	1	1
VI-21	VI	C6	C6	F5	H	Be	Th	Be	Th	1	1	1	1
VI-22	VI	C6	C6	F6	H	Be	Be	Be	Th	1	3	1	1
VI-23	VI	C6	H	F8	H	Be	Th	Be	Th	8	1	8	1
VI-24	VI	C7	C7	H	F8	Be	Be	Be	Be	1	1	1	1
VI-25	VI	C8	C8	H	F9	Be	Th	Be	Be	1	1	1	1
VI-26	VI	C8	C8	F12	H	Be	Be	Be	Be	1	1	1	1
VI-27	VI	C8	C8	H	F12	Be	Th	Be	Be	1	1	1	1
VI-28	VI	C9	C9	H	F6	Be	Be	Be	Be	1	1	1	1
VI-29	VI	C10	C10	H	F20	Be	Th	Be	Be	1	1	1	1
VI-30	VI	C20	H	H	F8	Be	Be	Be	Be	1	1	1	1
VI-31	VI	C6	C6	F6	F6	-	Th	-	Be	0	1	0	1
VI-32	VI	C6	C6	C2F9	C2F9	-	Be	-	Be	0	5	0	1
VI-33	VI	C6	C6	H	F6	-	Th	-	Be	0	1	0	1
VI-34	VI	H	C6	F6	F6	-	Al2	-	Th	0	1	0	1
VI-35	VI	C6	C6	F6	F6	-	Ac1	-	Th	0	1	0	1
VI-36	VI	C6	C6	F4	H	-	Th	-	Th	0	1	0	3
VI-37	VI	C6	C6	F5	H	-	Th	-	Be	0	1	0	1
VI-38	VI	C8	C8	F6	H	-	Th	-	Th	0	1	0	5

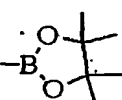
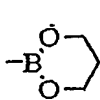
Table 5

No.	General Formula	R1	R2	R3	R4	A2	Y
VII-1	VII	H	C6	H	F6	Th	2
VII-2	VII	H	C10	H	F10	Be	4
VII-3	VII	H	C12	H	F6	Th	2
VII-4	VII	C8	H	F6	H	Be	2
VII-5	VII	C12	H	H	F4	Th	2
VII-6	VII	C6	H	F7	H	Be	2
VII-7	VII	C6	C6	F8	H	Th	4
VII-8	VII	H	C6	F8	H	Be	6
VII-9	VII	C7	C7	H	F8	Th	2
VII-10	VII	H	C12	H	OC3F4	Th	2

A general process for producing the  $\pi$ -conjugated compound is explained by reference to Exemplifying compounds (IV-8), (IV-12), and (VI-7) without limiting the production process of the present invention.





Hal : H, Cl, Br, I    Me : Zn, Mg    Bor : B(OH)<sub>2</sub>,  

Firstly, 3-halogenothiophene and perfluorooctyl iodide are allowed to react with each other to obtain Compound 1 (References: (1) J. Org. Chem. 1997, 62, 7128; (2) J. Fluorine Chem., 1985, 27, 291). Then the position 2 of the compound is halogenated to obtain Compound 2 (Reference: J. Org. Chem. 1968, 33, 2902). Separately, 3,4-dihalogenothiophene is allowed to react with two equivalents of hexylmagnesium bromide to obtain Compound 3 (Reference: Tetrahedron 1982, 38, 22, 3347). Then

this compound is halogenated at positions 2 and 3 to obtain Compound 4 (References: (1) Bull. Chem. Soc. Jpn, 1991, 64, 2566; (2) Chem. Mater. 1994, 6, 401). After Compound 2 is allowed to react with magnesium  
5 or zinc to obtain a metal halide, two equivalents of this halide is allowed to react with Compound 4 to obtain Compound 5. This Compound 5 is halogenated in the same manner as in the preparation of Compound 4 to obtain Compound 6 (References: (1) J. Am. Chem.  
10 Soc., 1995, 117, 233; (2) Chem. Mater. 1994, 6, 401). With this compound, 1,4-phenylene-bis-boric acid or a derivative thereof is allowed to react to obtain a  $\pi$ -conjugated compound (IV-12) of the present invention.

Separately, Compound 6 is allowed to react with  
15 2-thiophene-boric acid or a derivative thereof to prepare Compound 7, which is halogenated to prepare a dihalide 8. The dihalide 8 is allowed to react with 2,5-thiophene-diboric acid or a derivative thereof to obtain a  $\pi$ -conjugated compound (IV-8) of the present  
20 invention.

Separately, a metal halide derived from Compound 2 is allowed to react with an equivalent amount of Compound 4 to prepare Compound 9. This Compound 9 is allowed to react with 2,5-thiophene-  
25 diboric acid or a derivative thereof to obtain Compound 10. This compound is halogenated to obtain the dihalide 11. The dihalide is allowed to react

with 1,4-phenylene-bis-boric acid or a derivative thereof to obtain a  $\pi$ -conjugated compound (VI-7) of the present invention.

The halogenating agent useful in the above  
5 reactions includes iodine, bromine, N-bromosuccinimide, benzyltrimethylammonium tetrachloroiodide, benzyltrimethylammonium tribromide, benzyltrimethylammonium dichloro-iodide, and so forth.

The conductive organic thin film of the present  
10 invention contains preferably the aforementioned  $\pi$ -conjugated compound, and preferably the thin film is oriented. The method for the alignment includes rubbing methods, temperature-gradation methods, frictional transfer methods, and application of a  
15 magnetic field or an electric field.

The conductive organic thin film of the present invention may contain a suitable dopant for adjustment of the electric conductivity thereof. The dopant includes acceptors such as I<sub>2</sub>, Br<sub>2</sub>, Cl<sub>2</sub>, ICl,  
20 BF<sub>3</sub>, PF<sub>5</sub>, H<sub>2</sub>SO<sub>4</sub>, FeCl<sub>3</sub>, and TCNQ (tetracyanoquinodimethane); donors such as Li, K, Na, Eu; and surfactants such as alkyl sulfonate salts, and alkylbenzene sulfonate salts.

The method of formation of the conductive  
25 organic thin film of the present invention is not limited, and includes electrolytic polymerization methods, casting methods, spin-coating methods,



immersion coating methods, screen printing methods, micro-molding methods, micro-contact methods, roll application methods, ink-jet methods, and LB methods. The organic thin film can be patterned in an intended  
5 shape by photolithography and etching, soft lithography, an ink-jet method, or a like method.

The present invention relates also to a field effect type organic transistor employing the aforementioned  $\pi$ -conjugated compound or the  
10 aforementioned conductive organic thin film. The field effect type organic transistor of the present invention may have a structure of a planar type, a stagger type, or an inversed stagger type. The structure of a field effect type organic transistor  
15 of the present invention is explained by reference to a planar type thereof shown in Fig. 5. Fig. 5 is a schematic sectional view of a field-effect type organic transistor of the present invention. In Fig. 5, the field-effect type organic transistor of the  
20 present invention is constituted of insulating substrate 51, gate electrode 52 placed thereon, gate insulating layer 53 placed thereon, source electrode 54 and drain electrode 55 placed thereon, organic semiconductor layer 56 placed thereon, and protection  
25 layer 57 as the outermost layer.

The material of the gate insulation layer is not limited specially, and includes inorganic

materials such as  $\text{SiO}_2$ ,  $\text{SiN}$ ,  $\text{Al}_2\text{O}_3$ , and  $\text{Ta}_2\text{O}_5$ ; organic materials such as polyimide, polyacrylonitrile, polytetrafluoroethylene, polyvinyl alcohol, polyvinylphenol, polyethylene terephthalate, and  
5 polyvinylidene fluoride; and organic-inorganic hybrid materials. These materials may be laminated in two or more layers. This lamination is effective to increase the dielectric strength. Of the materials, organic compounds are preferred since the organic  
10 materials can be formed into a film by a low-cost liquid phase process.

The material of the insulating substrate is not specially limited, and includes inorganic materials such as glass, and quartz; photosensitive polymer  
15 materials such as of acrylic type, vinyl type, ester type, imide type, urethane type, diazo type, and cinnamoyl type; organic materials such as polyvinylidene fluoride, polyethylene terephthalate, and polyethylene; and organic-inorganic hybrid  
20 materials.

Any electroconductive material may be used for the gate electrode, the source electrode, and the drain electrode, provided that the material is electroconductive. The material includes metallic  
25 materials such as Al, Cu, Ti, Au, Pt, Ag, and Cr; inorganic materials such as polysilicon, silicides, ITO (indium-tin oxide), and  $\text{SnO}_2$ ; highly doped

electroconductive polymers such as polypyridine, polyacetylene, polyaniline, polypyrrol, and polythiophene; and electroconductive ink containing carbon particles, silver particles, or the like  
5 dispersed therein. In particular, for use for flexible electronic paper sheets or the like, the electrodes are preferably formed from an electroconductive polymer, an electroconductive ink containing carbon particles or silver particles  
10 dispersed therein, or the like because of the ease for adjusting the thermal expansion to be equal to that of the substrate.

The methods of forming the electrodes and the gate insulation layer are not specially limited. For  
15 the formation with an organic material, the method includes electrolytic polymerization methods, casting methods, spin-coating methods, immersion coating method, screen printing methods, micro-molding methods, micro-contact methods, roll application  
20 methods, ink-jet methods, and LB methods. Depending on the material, effective method for the formation includes vacuum vapor deposition, CVD, electron beam vapor deposition, resistance-heating vapor deposition, and sputtering.

25 These electrodes and films can be patterned in an intended design by photolithography and etching treatment. Soft lithography, and an ink-jet method

are effective in the patterning. An extraction electrode for the respective electrodes and a protection layer may be formed, as necessary.

#### Industrial Availability

5       The present invention is applicable to electronic devices, particularly to field effect type organic transistors, having a conductive organic thin film useful in electronic fields such as display devices, information tags, and ICs.

#### 10   (Example 1)

##### Preparation of Exemplifying compound (IV-36)

##### (1) Preparation of 3,4-Dibutylthiophene

Butylmagnesium bromide (140 mmol) was added dropwise at 0°C to a mixture solution of 3,4-  
15   dibromothiophene (50 mmol) and [1,3-bis(diphenylphosphino)propane]dichloronickel(II) (0.3 mmol) in 100 mL of dry diethyl ether. The resulting mixture was heated and refluxed for 6 hours. The reaction mixture was combined with water, and  
20   extracted with diethyl ether. The extract solution was dried over magnesium sulfate, and the solvent was evaporated therefrom to obtain a crude product. The crude product was purified by silica gel column chromatography and by distillation to obtain the  
25   intended product (32 mmol) in a 64% yield.

##### (2) Preparation of 2,5-Dibromo-3,4-Dibutylthiophene

Bromine (67 mmol) was added dropwise to a

solution of 3,4-dibutylthiophene (30 mmol) in a mixture of 25 mL of glacial acetic acid and 10 mL of dichloromethane at room temperature, and the mixture was stirred for two hours. The resulting reaction mixture was combined with water, and extracted with diethyl ether. The extract solution was dried over magnesium sulfate, and the solvent was evaporated therefrom to obtain a crude product. The crude product was purified by silica gel column chromatography to obtain the intended product (27 mmol) in a 90% yield.

(3) Preparation of 3-Perfluorobutylthiophene

3-Iodothiophene (50 mmol) and perfluorobutyl iodide (60 mmol) were added to a mixture of copper powder (0.16 mmol) and 60 mL of N,N-dimethylformamide. The resulting mixture was stirred in a nitrogen atmosphere at 130°C for 24 hours. The reaction mixture was filtered to remove the solid matter. The filtrate was mixed with 3N-hydrochloric acid, and was extracted with hexane. The extract solution was washed with a sodium thiosulfate solution, and dried over magnesium sulfate. The solvent was evaporated therefrom to obtain a crude product. The crude product was purified by distillation to obtain the intended product (31 mmol) in a 62% yield.

(4) Preparation of 2-Bromo-4-Perfluorobutylthiophene

A solution of 3-perfluorobutylthiophene (30

mmol) and N-bromosuccinimide (33 mmol) in a mixture of 25 mL of chloroform and 25 mL of acetic acid was stirred at room temperature for 5 minutes. The reaction mixture was combined with water, and  
5 extracted with chloroform. The extract solution was washed with an aqueous 10% potassium hydroxide solution, and water successively, and dried over magnesium sulfate. The solvent was evaporated to obtain a crude product. The crude product was  
10 purified by distillation to obtain the intended product (26 mmol) in an 87% yield.

(5) Preparation of 3',4'-Dibutyl-4,4''-  
Diperfluorobutyl-[2,2';5',2'']terthiophene

On an ice bath, 1.0 g of magnesium was placed  
15 in dry diethyl ether. Thereto was added dropwise a liquid mixture of 2-bromo-4-perfluorobutylthiophene (25 mmol) and 20 mL of dry diethyl ether. Thereto was added 80 mL of dry diethyl ether. The mixture was refluxed for one hour to obtain a Grignard  
20 reagent. On a dry ice/acetone bath, the above-prepared Grignard reagent was added through a syringe dropwise into a solution of 2,5-dibromo-3,4-dibutylthiophene (10 mmol) and [1,3-bis(diphenylphosphino)ferrocene]dichloropalladium (50  
25 mg) in 100 mL of dry diethyl ether. The resulting mixture was stirred at room temperature for three days. The reaction mixture was combined with water,

and was extracted with diethyl ether. The extract solution was washed with water, and dried over magnesium sulfate. The solvent was evaporated therefrom to obtain a crude product. The crude product was purified by column chromatography to obtain the intended product (7.2 mmol) at a 72% yield.

(6) Preparation of 5,5''-Dibromo-3',4'-Dibutyl-4,4''-Diperfluorobutyl-[2,2';5',2'']terthiophene

A solution of 3',4'-dibutyl-4,4''-diperfluorobutyl-[2,2';5',2'']terthiophene (5 mmol) and N-bromosuccinimide (12 mmol) in a mixture of 15 mL of chloroform and 15 mL of acetic acid was stirred at room temperature for 5 minutes. The reaction mixture was combined with water, and extracted with chloroform. The extract solution was washed with an aqueous 10% potassium hydroxide solution, and water successively, and dried over magnesium sulfate. The solvent was evaporated to obtain a crude product. The crude product was purified by distillation to obtain the intended product (4.2 mmol) in an 84% yield.

(7) Preparation of Exemplifying compound (IV-36)

Tetrakis(triphenylphosphine)palladium (0.04 mmol) and 3 mL of an aqueous 2N sodium carbonate solution were added to a mixture solution of 5,5''-dibromo-3',4'-dibutyl-4,4''-diperfluorobutyl-[2,2';5',2'']terthiophene (2.0 mmol) and 2,5-

thiophene-diboric acid (2.0 mmol) in 10 mL of benzene in a nitrogen atmosphere. The resulting mixture was refluxed for 24 hours. The reaction mixture was poured into a large amount of acetone to obtain a crude product. The crude product was purified by repeated reprecipitation to obtain the intended Exemplifying compound (IV-36) in a 45% yield. The obtained Exemplifying compound (IV-36) had a molecular weight of Mn: 23,400; Mw:32,800 according to GPC measurement (solvent: chloroform).

(Example 2)

Preparation of Exemplifying compound (IV-10)

(1) Preparation of 3'',4''-Dibutyl-3',4''' - Diperfluorobutyl-[2,2';5',2'';5'',2''' ;5''',2'''']-quinquethiophene

Tetrakis(triphenylphosphine)palladium (0.04 mmol) and 3 mL of an aqueous 2N sodium carbonate were added to a mixture solution of 5,5''-dibromo-3',4'-dibutyl-4,4''-diperfluorobutyl-[2,2';5',2'']-terthiophene (2 mmol) and 2-thiophene-boric acid (4 mmol) in 10 mL of benzene in nitrogen atmosphere. The resulting mixture was refluxed for 24 hours. The reaction mixture was combined with water, and extracted with chloroform. The extract solution was washed with water, and dried over magnesium sulfate. The solvent was evaporated to obtain a crude product. The crude product was purified by column



chromatography to obtain the intended product (1.6 mmol) in an 80% yield.

(2) Preparation of 5,5''' -Dibromo-3'',4''-Dibutyl-3',4''' -Diperfluorobutyl-

5 [2,2';5',2'';5'',2''' ;5''' ,2'''' ]- quinquethiophene

A liquid mixture of 3'',4''-dibutyl-3',4''' -diperfluorobutyl-[2,2';5',2'';5'',2''' ;5''' ,2'''' ]-quinquethiophene (1.5 mmol), N-bromosuccinimide (3.5 mmol), 15 mL of chloroform, and 15 mL of acetic acid  
10 was stirred at room temperature for 5 minutes. The reaction mixture was combined with water, and was extracted with chloroform. The extract solution was washed with an aqueous 10% potassium hydroxide solution, and water successively, and dried over  
15 magnesium sulfate. The solvent was evaporated to obtain a crude product. The crude product was purified by distillation to obtain the intended product (1.2 mmol) in an 80% yield.

(3) Preparation of Exemplifying compound (IV-10)

20 Tetrakis(triphenylphosphine)palladium (0.02 mmol) and 3 mL of an aqueous 2N sodium carbonate solution were added to a mixture liquid of 5,5''' -Dibromo-3'',4''-Dibutyl-3',4''' -Diperfluorobutyl-[2,2';5',2'';5'',2''' ;5''' ,2'''' ]quinquethiophene (1.0  
25 mmol), 1,4-phenylene-bisboric acid (1.0 mmol), and 8 mL of benzene in a nitrogen atmosphere. The resulting mixture was refluxed for 24 hours. The

reaction mixture was poured into a large amount of acetone to obtain a crude product. The crude product was purified by repeated reprecipitation to obtain the intended Exemplifying compound (IV-10) in a 34%  
5 yield. The obtained Exemplifying compound (IV-10) had a molecular weight of Mn: 22,100; Mw: 33,400 according to GPC measurement (solvent: chloroform).  
(Example 3)

#### Preparation of Exemplifying compound (VI-14)

##### 10 (1) Preparation of 3,4-Didecylthiophene

Decylmagnesium bromide (140 mmol) was added dropwise at 0°C to a mixture solution of 3,4-dibromothiophene (50 mmol) and [1,3-bis(diphenylphosphino)propane]dichloronickel(II) (0.3  
15 mmol) in 100 mL of dry diethyl ether. The resulting mixture was heated and refluxed for 6 hours. The reaction mixture was combined with water, and extracted with diethyl ether. The extract solution was dried over magnesium sulfate, and the solvent was  
20 evaporated therefrom to obtain a crude product. The crude product was purified by silica gel column chromatography and by distillation to obtain the intended product (38 mmol) in a 76% yield.

##### (2) Preparation of 2,5-Dibromo-3,4-Didecylthiophene

25 Bromine (67 mmol) was added dropwise to a solution of 3,4-didecylthiophene (30 mmol) in a mixture of 25 mL of glacial acetic acid and 10 mL of

dichloromethane at room temperature, and the resulting mixture was stirred for two hours. The reaction mixture was combined with water, and extracted with diethyl ether. The extract solution was dried over magnesium sulfate, and the solvent was evaporated therefrom to obtain a crude product. The crude product was purified by silica gel column chromatography to obtain the intended product (25 mmol) in an 83% yield.

10 (3) Preparation of 3-Perfluorooctylthiophene

3-Iodothiophene (50 mmol) and perfluorooctyl iodide (60 mmol) were added to a mixture of copper powder (0.16 mmol) and 60 mL of N,N-dimethylformamide. The resulting mixture was stirred in a nitrogen atmosphere at 130°C for 24 hours. The reaction mixture was filtered to remove the solid matter. The filtrate was combined with 3N-hydrochloric acid, and was extracted with hexane. The extract solution was washed with a sodium thiosulfate solution, and dried over magnesium sulfate. The solvent was evaporated therefrom to obtain a crude product. The crude product was purified by distillation to obtain the intended product (30 mmol) in a 60% yield.

(4) 2-Bromo-4-Perfluorooctylthiophene

25 A solution of 3-perfluorooctylthiophene (30 mmol) and N-bromosuccinimide (33 mmol) in a mixture of 25 mL of chloroform and 25 mL of acetic acid was

stirred at room temperature for 5 minutes. The reaction mixture was combined with water, and extracted with chloroform. The extract solution was washed with an aqueous 10% potassium hydroxide solution, and water successively, and dried over magnesium sulfate. The solvent was evaporated to obtain a crude product. The crude product was purified by distillation to obtain the intended product (24 mmol) in an 80% yield.

10 (5) Preparation of 2-Bromo-3,4-Didecyl-4'-Perfluorooctyl-2,2'-bithiophene

On an ice bath, 1.0 g of magnesium was placed in dry diethyl ether. Thereto was added dropwise a liquid mixture of 2-bromo-4-perfluorooctylthiophene (10 mmol) and 20 mL of dry diethyl ether. Thereto was added 80 mL of dry diethyl ether. The mixture was refluxed for one hour to obtain a Grignard reagent. On a dry ice/acetone bath, the above-prepared Grignard reagent was added through a syringe dropwise into a solution of 2,5-dibromo-3,4-didecylthiophene (10 mmol) and [1,3-bis(diphenylphosphino)ferrocene]-dichloropalladium (50 mg) in 100 mL of dry diethyl ether. The resulting mixture was stirred at room temperature for three days. The reaction mixture was combined with water, and was extracted with diethyl ether. The extract solution was washed with water, and dried

over magnesium sulfate. The solvent was evaporated therefrom to obtain a crude product. The crude product was purified by column chromatography to obtain the intended product (5.4 mmol) at a 54% yield.

- 5 (6) Preparation of 3',4',3''' ,4''' -tetradecyl-4,4''' -diperfluorooctyl-[2,2';5',2";5'',2''' ;5''' ,2''' ]-quinquethiophene

To a mixture solution of 2-bromo-3,4-didecyl-4'-perfluorooctyl-2,2'-bithiophene (5.0 mmol) and 2,5-  
 10 thiophene-diboric acid (2.5 mmol) in 10 mL of benzene, were added tetrakis(triphenylphosphine)palladium (0.08 mmol) and 6 mL of an aqueous 2N sodium carbonate solution in a nitrogen atmosphere. The resulting mixture was refluxed for 24 hours. The  
 15 reaction mixture is combined with water and was extracted with chloroform. The extract solution was washed with water, and was dried over magnesium sulfate. The solvent was evaporated to obtain a crude product. The crude product was purified by  
 20 column chromatography to obtain the intended product (4.1 mmol) at an 82% yield.

- (7) Preparation of 5,5''' -Dibromo-3',4',3''' ,4''' ⊕ Tetradecyl-4,4''' -Diperfluorooctyl-[2,2';5',2";5'',2''' ;5''' ,2''' ]quinquethiophene

25 A solution of 3',4',3''' ,4''' -tetradecyl-4,4''' -diperfluorooctyl-[2,2';5',2";5'',2''' ;5''' ,2''' ]-quinquethiophene (1.5 mmol) and N-bromosuccinimide

(3.5 mmol) in a mixture of 15 mL of chloroform and 15 mL of acetic acid was stirred at room temperature for 5 minutes. The reaction mixture was combined with water, and extracted with chloroform. The extract  
5 solution was washed with an aqueous 10% potassium hydroxide solution, and water successively, and dried over magnesium sulfate. The solvent was evaporated to obtain a crude product. The crude product was purified by distillation to obtain the intended  
10 product (0.8 mmol) in a 53% yield.

(8) Preparation of Exemplifying compound (VI-14)

Tetrakis(triphenylphosphine)palladium (0.02 mmol) and 2 mL of an aqueous 2N sodium carbonate solution were added to a mixture solution of 5,5''' -  
15 dibromo-3',4',3''' ,4''' -tetradecyl-4,4''' -diperfluorooctyl-[2,2';5',2";5'',2''' ;5''' ,2'''' ]-quinquethiophene (0.5 mmol) and 2,5-thiophene-diboric acid (0.5 mmol) in 5 mL of benzene in a nitrogen atmosphere. The resulting mixture was refluxed for  
20 24 hours. The reaction mixture was poured into a large amount of acetone to obtain a crude product. The crude product was purified by repeated reprecipitation to obtain the intended Exemplifying compound (VI-14) in a 44% yield. The obtained  
25 Exemplifying compound (VI-14) had a molecular weight of Mn: 43,100, Mw: 55,100 according to GPC measurement (solvent: chloroform).

(Example 4)

Fig. 6 is a schematic sectional view of the field effect type organic transistor of this Example. Gate electrode 61 was a highly doped n-type silicon substrate. Gate insulating layer 62 was formed from SiO<sub>2</sub>. Source electrode 63 and drain electrode 64 were formed from gold. Organic semiconductor layer 65 was formed from Exemplifying compound (IV-36) prepared in Example 1. The production process of the transistor is described below.

A thermal oxidation film SiO<sub>2</sub> (300 nm) was formed on a silicon substrate. Thereon, a source electrode and a drain electrode of chromium (5 nm)/gold (100 nm) were formed respectively with a channel length 50  $\mu$ m and a channel breadth 50 mm. Further thereon, organic semiconductor layer 65 was formed by applying a solution of Exemplifying compound (IV-36) in chloroform (0.01 g/mL) by spin coating and drying the applied solution at 120°C for 12 hours. The gate electrode, the drain electrode and the source electrode were wired respectively with gold wires of 0.1 mm diameter and a silver paste to complete a field effect type organic transistor element.

Next, the drain current was measured in the gate voltage range from 0 V to -50 V and in the range of the voltage between the source and drain

electrodes from 0 V to -50 V. The threshold voltage  $V_{th}$  was derived by extrapolating the relation between the square root of the drain current and the gate voltage to drain current  $I_d=0$ . Further, the carrier mobility  $\mu$  was calculated according to Formula (i) below:

$$\mu = I_d / \{ (W/2L) C_i (V_g - V_{th})^2 \} \quad (i)$$

(in the Formula,  $\mu$  denotes a mobility;  $I_d$ , a drain current (A);  $W$ , a channel breadth (cm);  $L$ , a channel length (cm);  $C_i$ , a capacity ( $F/cm^2$ ) for a unit area of the gate insulating layer;  $V_g$ , a gate voltage (V); and  $V_{th}$ , a threshold voltage (V)).

Further, the on-off ratio was calculated from the ratio of the drain current at the gate voltage of 0 V and the voltage between the source and drain electrodes of -50 V (off current) to the drain current at the gate voltage of -50 V and the voltage between the source and drain electrodes of -50 V (on current). The calculation results are shown below.

20	Mobility	$1.2 \times 10^{-1} \text{ cm}^2/\text{Vs}$
	On-off ratio	$1.8 \times 10^6$

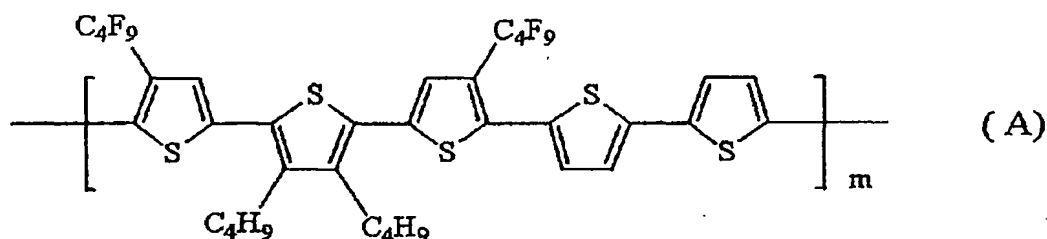
This element was left standing in the open air at room temperature for three months. Thereafter the same measurement was conducted as above. The change was less than 10%.

(Comparative Example 1)

Comparative Compound (A) shown below was



prepared for comparison with Exemplifying compound (IV-36), a  $\pi$ -conjugated compound of the present invention.



5

The preparation process is described below.

Tetrakis(triphenylphosphine)palladium (0.04 mmol) and 3 mL of an aqueous 2N sodium carbonate solution were added to a mixture solution of 5,5'-dibromo-3',4'-dibutyl-4,4''-diperfluorobutyl-[2,2';5',2'']terthiophene (2 mmol) and 2,2'-dithiophene-5,5'-diboric acid (2 mmol) in 10 mL of benzene in a nitrogen atmosphere. The resulting mixture was refluxed for 24 hours. The reaction mixture was poured into a large amount of acetone to obtain a crude product of Comparative Compound (A). This crude product was purified by repeated reprecipitation to obtain the intended Comparative Compound (A) in a 31% yield. The obtained Comparative Compound (A) had a molecular weight of Mn: 19,300; Mw: 31,800 according to GPC measurement (solvent: chloroform).

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A field effect type organic transistor was

prepared in the same manner as in Example 4 except that Comparative Compound (A) was used in place of Exemplifying compound (IV-36) used in Example 4. The mobility was measured in the same manner as in

5 Example 4. The results are shown below.

Mobility	$8.2 \times 10^{-3} \text{ cm}^2/\text{Vs}$
On-off ratio	$7.4 \times 10^3$

(Example 5)

Fig. 6 is a schematic sectional view of the  
10 field effect type organic transistor employed in this Example. Gate electrode 61 was a highly doped n-type silicon substrate. Gate insulating layer 62 was formed from polyvinylphenol. Source electrode 63 and drain electrode 64 were formed from gold. Organic  
15 semiconductor layer 65 was formed from Exemplifying compound (IV-10) prepared in Example 2. The production process of the transistor is described below.

On a silicon substrate, a gate insulation layer  
20 was formed by applying a solution of polyvinylphenol in 2-propanol (0.1 g/mL) by spin coating and drying the applied solution at 150°C for 6 hours. Thereon, a source electrode and a drain electrode were formed from gold (50 nm) by vapor deposition with a channel  
25 length of 50  $\mu\text{m}$  and a channel breadth of 10 mm respectively. Further thereon, organic semiconductor layer 65 was formed by applying a solution of

Exemplifying compound (IV-10) in chloroform (0.01 g/mL) by spin coating and drying the applied solution at 120°C for 12 hours. The gate electrode, the drain electrode, and the source electrode were wired  
 5 respectively with gold wires of 0.1 mm diameter and a silver paste to complete a field effect type organic transistor element.

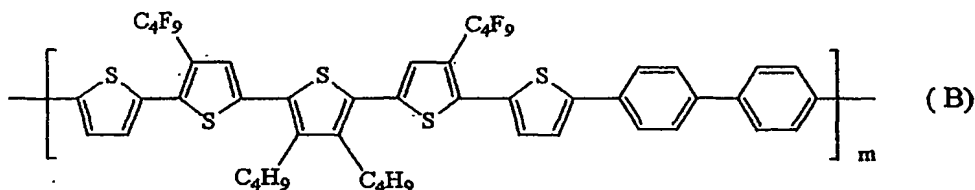
The mobility was measured in the same manner as in Example 4. The results are shown below.

10	Mobility	$8.2 \times 10^{-2} \text{ cm}^2/\text{Vs}$
	On-off ratio	$5.2 \times 10^5$

This element was left standing in the open air at room temperature for three months. Thereafter the same measurement was conducted as above. The change  
 15 was less than 10%.

(Comparative Example 2)

Comparative Compound (B) shown below was prepared for comparison with Exemplifying compound (IV-10), a  $\pi$ -conjugated compound of the present  
 20 invention.



The preparation process is described below.

Tetrakis(triphenylphosphine)palladium (0.02

mmol) and 3 mL of an aqueous 2N sodium carbonate solution were added to a mixture liquid of 5,5''' - dibromo-3'',4''-dibutyl-3',4''' -diperfluorobutyl-[2,2';5',2'';5'',2''' ;5''' ,2'''' ]quinquethiophene (1.0 mmol), 4,4'-biphenyl-bisboric acid (1.0 mmol), and 8 mL of benzene in a nitrogen atmosphere. The resulting mixture was refluxed for 24 hours. The reaction mixture was poured into a large amount of acetone to obtain a crude product. This crude product was purified by repeated reprecipitation to obtain the intended Comparative Compound (B) in a 29% yield. The obtained Comparative Compound (B) had a molecular weight of Mn: 21,300; Mw: 30,000 according to GPC measurement (solvent: chloroform).

A field effect type organic transistor was prepared in the same manner as in Example 5 except that Comparative Compound (B) was used in place of Exemplifying compound (IV-10) used in Example 5. The mobility was measured in the same manner as in Example 4. The results are shown below.

Mobility	$1.5 \times 10^{-3} \text{ cm}^2/\text{Vs}$
On-off ratio	$3.7 \times 10^3$

(Example 6)

Fig. 7 is a schematic sectional view of a field effect type organic transistor employed in this Example. Gate electrode 71 was a highly doped n-type silicon substrate. Gate insulating layer 72 was

formed from polyvinylphenol. Source electrode 73 and drain electrode 74 were formed from gold. Organic semiconductor layer 75 was formed from Exemplifying compound (VI-14) prepared in Example 3. The  
5 production process of the transistor is described below.

On a silicon substrate, a gate insulation layer was formed by applying a solution of polyvinylphenol in 2-propanol (0.1 g/mL) by spin coating and drying  
10 the applied solution at 150°C for 6 hours. Thereon, organic semiconductor layer 65 was formed by applying a solution of Exemplifying compound (VI-14) in chloroform (0.01 g/mL) by spin coating and drying the applied solution at 120°C for 12 hours. Further  
15 thereon, a source electrode and a drain electrode were formed from gold (50 nm) by vacuum vapor deposition respectively with a channel length of 50  $\mu\text{m}$  and a channel breadth of 10 mm. The gate electrode, the drain electrode and the source  
20 electrode were wired respectively with gold wires of 0.1 mm diameter and a silver paste to complete a field effect type organic transistor element.

The mobility was measured in the same manner as in Example 4. The results are shown below.

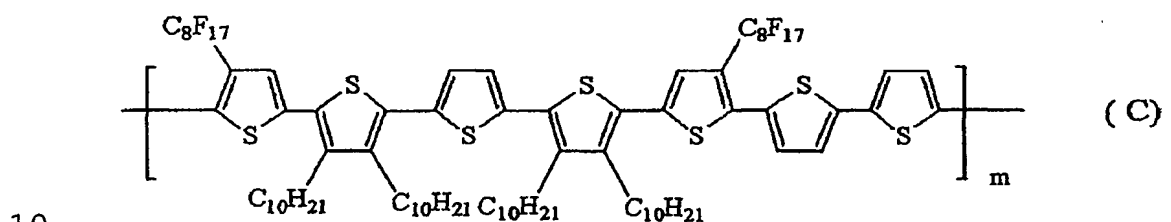
25	Mobility	$1.4 \times 10^{-1} \text{ cm}^2/\text{Vs}$
	On-off ratio	$2.4 \times 10^6$

This element was left standing in the open air

at room temperature for three months. Thereafter the same measurement was conducted as above. The change was less than 10%.

(Comparative Example 3)

5 Comparative Compound (C) shown below was prepared for comparison with Exemplifying compound (VI-14), a  $\pi$ -conjugated compound of the present invention.



The preparation process is described below.

15 Tetrakis(triphenylphosphine)palladium (0.02 mmol) and 2 mL of an aqueous 2N sodium carbonate solution were added to a mixture liquid of 5,5''' - dibromo-3',4',3''' ,4''' -tetradecyl-4,4''' -  
 20 diperfluorooctyl-[2,2';5',2";5",2''' ;5''' ,2''' ]- quinquethiophene (0.5 mmol), 2,2'-dithiophene-5,5'- diboric acid (0.5 mmol), and 5 mL of benzene in a nitrogen atmosphere. The resulting mixture was  
 refluxed for 24 hours. The reaction mixture was poured into a large amount of acetone to obtain a crude product. This crude product was purified by repeated reprecipitation to obtain the intended Comparative Compound (C) in a 28% yield. The

obtained Comparative Compound (C) had a molecular weight of Mn: 35,100; Mw: 39,100 according to GPC measurement (solvent: chloroform).

A field effect type organic transistor was prepared in the same manner as in Example 6 except that Comparative Compound (C) was used in place of Exemplifying compound (VI-14) used in Example 6. The mobility was measured in the same manner as in Example 4. The results are shown below.

10	Mobility	$9.1 \times 10^{-3} \text{ cm}^2/\text{Vs}$
	On-off ratio	$7.3 \times 10^3$

(Example 7)

Fig. 7 is a schematic sectional view of a field effect type organic transistor employed in this Example. Gate electrode 71 was a highly doped n-type silicon substrate. Gate insulating layer 72 was formed from polyimide. Source electrode 73 and drain electrode 74 were formed from gold. Organic semiconductor layer 75 was formed from Exemplifying compound (VI-14) prepared in Example 3. The production process of the transistor is described below.

On a silicon substrate, a gate insulation layer was formed by applying a polyamic acid by spin coating and baking the applied polyamic acid at 200°C to form a polyimide film. Thereon, organic semiconductor layer 65 was formed by applying a

solution of Exemplifying compound (VI-14) in chloroform (0.01 g/mL) by spin coating and drying the applied solution at 120°C for 12 hours. The surface of this layer was rubbed with cloth for rubbing treatment. Further thereon, a source electrode and a drain electrode were formed from gold (50 nm) by vacuum vapor deposition respectively with a channel length of 50  $\mu\text{m}$  and a channel breadth of 10 mm. The electrodes were arranged to allow the current to flow parallel to the rubbing direction. The gate electrode, the drain electrode, and the source electrode were wired respectively with gold wires of 0.1 mm diameter and a silver paste to complete a field effect type organic transistor element.

The mobility was measured in the same manner as in Example 4. The results are shown below.

Mobility	$5.2 \times 10^{-1} \text{ cm}^2/\text{Vs}$
On-off ratio	$1.2 \times 10^7$

This element was left standing in the open air at room temperature for three months. Thereafter the same measurement was conducted as above. The change was less than 10%.

(Example 8)

Fig. 7 is a schematic sectional view of a field effect type organic transistor employed in this Example. Gate electrode 71 was a highly doped n-type silicon substrate. Gate insulating layer 72 was



formed from polyimide. Source electrode 73 and drain electrode 74 were formed from gold. Organic semiconductor layer 75 was formed from Exemplifying compound (VI-14) prepared in Example 3. The  
5 production process of the transistor is described below.

On a silicon substrate, a gate insulation layer was formed by applying a polyamic acid by spin coating and baking the applied polyamic acid at 200°C  
10 to form a polyimide film. Thereon, organic semiconductor layer 65 was formed by applying a solution of Exemplifying compound (VI-14) in chloroform (0.01 g/mL) by spin coating and drying the applied solution at 120°C for 12 hours. The surface  
15 of this layer was rubbed with cloth for rubbing treatment. Further thereon, a source electrode and a drain electrode were formed from gold (50 nm) by vacuum vapor deposition respectively with a channel length 50  $\mu$ m and a channel breadth 10 mm. The  
20 electrodes were arranged to allow the current to flow perpendicularly to the rubbing direction. The gate electrode, the drain electrode, and the source electrode were wired respectively with gold wires of 0.1 mm diameter and a silver paste to complete a  
25 field effect type organic transistor element.

The mobility was measured in the same manner as in Example 4. The results are shown below.

Mobility	$1.1 \times 10^{-1} \text{ cm}^2/\text{Vs}$
On-off ratio	$2.0 \times 10^6$

This element was left standing in the open air at room temperature for three months. Thereafter the same measurement was conducted as above. The change was less than 10%.

By comparison of Example 4 with Comparative Example 1, Example 5 with Comparative Example 2, and Example 6 with Comparative 3, it is clear that the field effect type organic transistor of the present invention has high mobility and a high on-off ratio. (Example 9)

Preparation of Exemplifying compound (VII-3)

(1) Preparation of 3,5-Dibromo-2,2'-Bithiophene

15       Tetrakis(triphenylphosphine)palladium (3 mmol) and 100 mL of an aqueous 2N sodium carbonate solution were added to a solution of 2-thiophene-boric acid (5.0 mmol) and 2,3,5-tribromothiophene (100 mmol) in a mixture of 200 mL of toluene and 100 mL of ethanol in a nitrogen atmosphere. The resulting mixture was refluxed for 24 hours. The reaction mixture was combined with water, and extracted with toluene. The extract solution was washed with water, and dried over magnesium sulfate. The solvent was evaporated to obtain a crude product. The crude product was purified by column chromatography and by recrystallization from hexane to obtain the intended

product (22.1 mmol) in a 22% yield.

(2) Preparation of 4'-Bromo-3-Dodecyl-  
[2,2';5',2'']terthiophene

Tetrakis(triphenylphosphine)palladium (0.1  
5 mmol) and 3 mL of an aqueous 2N sodium carbonate  
solution were added to a solution of 3-dodecyl-2-  
thiophene-boric acid (3.1 mmol) and 3,5-dibromo-2,2'-  
bithiophene (3.1 mmol) in a mixture of 6 mL of  
toluene and 3 mL of ethanol in a nitrogen atmosphere.  
10 The resulting mixture was refluxed for 24 hours. The  
reaction mixture was combined with water, and  
extracted with hexane. The extract solution was  
washed with water, and dried over magnesium sulfate.  
The solvent was evaporated to obtain a crude product.  
15 The crude product was purified by column  
chromatography to obtain the intended product (2.52  
mmol) in an 80% yield.

(3) Preparation of 4'-Perfluorohexyl-3-Dodecyl-  
[2,2';5',2'']terthiophene

20 A mixture of perfluorohexyl iodide (2.6 mmol)  
and copper powder (5.16 mmol) in 3 mL of dry  
dimethylsulfoxide was stirred at 125°C for 1.5 hours  
in a nitrogen atmosphere. Thereto was added 4'-  
bromo-3-dodecyl-[2,2';5',2'']terthiophene (1.29 mmol)  
25 in 5 mL of dry dimethylsulfoxide. The resulting  
mixture was stirred at 120°C for 6 hours. After the  
reaction, hexane and water were added to the reaction

mixture. The mixture was filtered through Celite, and the filtrate was extracted with hexane. The extract solution was washed with water and dried over magnesium sulfate. Therefrom the solvent was  
5 evaporated to obtain a crude product. The crude product was purified by column chromatography to obtain the intended product (0.6 mmol) in a 47% yield.

(4) Preparation of 5,5''-Dibromo-4'-Perfluorohexyl-3-Dodecyl-[2,2';5'2'']terthiophene

10       A solution of 4'-perfluorohexyl-3-dodecyl-[2,2';5',2'']terthiophene (0.26 mmol) and N-bromosuccinimide (0.55 mmol) in a mixture of 2 mL of chloroform and 2 mL of acetic acid was stirred at room temperature for 5 hours. The reaction mixture  
15 was combined with water, and extracted with hexane. The extract solution was washed with an aqueous 10% potassium hydroxide solution, and water successively, and dried over magnesium sulfate. The solvent was evaporated to obtain a crude product. The crude  
20 product was purified by column chromatography to obtain the intended product (0.23 mmol) in a 90% yield.

(5) Preparation of Exemplifying compound (VII-3)

25       Tetrakis(triphenylphosphine)palladium (0.04 mmol) and 3 mL of an aqueous 2N sodium carbonate solution were added to a solution of 5,5''-dibromo-4-perfluorohexyl-3-dodecyl-[2,2';5'2'']terthiophene (2.0

mmol) and 2,5-thiophene-diboric acid (2.0 mmol) in 10 mL of benzene in a nitrogen atmosphere. The resulting mixture was refluxed for 24 hours. The reaction mixture was poured into a large amount of acetone to obtain a crude product. The crude product was purified by repeated reprecipitation to obtain the intended Exemplifying compound (VII-3) in a 35% yield. The obtained Exemplifying compound (VII-3) had a molecular weight of Mn: 13,400; Mw:22,300 according to GPC measurement (solvent: chloroform). (Example 10)

Preparation of Exemplifying compound (VII-10)

Tetrakis(triphenylphosphine)palladium (0.04 mmol) and 3 mL of an aqueous 2N sodium carbonate solution were added to a mixture liquid of 5,5"-dibromo-4'-perfluorobutylpentyloxy-3-dodecyl-[2,2';5'2'']terthiophene (2.0 mmol), 2,5-thiophene-diboric acid (2.0 mmol), and 10 mL of benzene in a nitrogen atmosphere. The resulting mixture was refluxed for 24 hours. The reaction mixture was poured into a large amount of acetone to obtain a crude product. The crude product was purified by repeated reprecipitation to obtain the intended Exemplifying compound (VII-10) in a 35% yield. The obtained Exemplifying compound (VII-10) had a molecular weight of Mn: 11,300; Mw:19,300 according to GPC measurement (solvent: chloroform).

(Example 11)

A field effect type organic transistor was prepared in the same manner as in Example 4 except that Exemplifying compound (VII-3) prepared in  
5 Example 9 was used in place of Exemplifying compound (IV-36) used in Example 4. The mobility was measured in the same manner as in Example 4. The results are shown below.

	Mobility	$2.2 \times 10^{-1} \text{ cm}^2/\text{Vs}$
10	On-off ratio	$5.2 \times 10^6$

This element was left standing in the open air at room temperature for three months. Thereafter the same measurement was conducted as above. The change was less than 10%.

15 (Example 12)

A field effect type organic transistor was prepared in the same manner as in Example 4 except that Exemplifying compound (VII-10) prepared in  
Example 10 was used in place of Exemplifying compound  
20 (IV-36) used in Example 4. The mobility was measured in the same manner as in Example 4. The results are shown below.

	Mobility	$2.7 \times 10^{-1} \text{ cm}^2/\text{Vs}$
	On-off ratio	$8.2 \times 10^6$

25 This element was left standing in the open air at room temperature for three months. Thereafter the same measurement was conducted as above. The change

was less than 10%.

This application claims priority from Japanese  
5 Patent Application No. 2004-018357 filed on January  
27, 2004, which is hereby incorporated by reference  
herein.